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PATENT
30205/37777

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Jae Chang Jung et al.)	I hereby certify that this paper and the
)	documents referred to as enclosed
Serial No.: 10/054,095)	therewith are being deposited with the
)	United States Postal Service as first class
Filed: January 22, 2002)	mail, postage prepaid, on February 19,
)	2004, in an envelope addressed to
For: Chemical Amplification)	Commissioner for Patents, P.O. Box
Photoresist Monomers, Polymers)	1450, Alexandria, Virginia 22313-1450
Therefrom and Photoresist)	
Compositions Containing the Same)	
)	
Group Art Unit: 1752)	Michael R. Hull
)	Reg. No. 35,902
Examiner: Rosemary E. Ashton)	Attorney for Applicants

COMMENT ON STATEMENT OF REASONS FOR ALLOWANCE

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

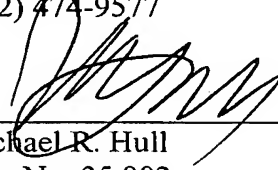
In addition to the reasons for allowance set forth in the allowance papers that were mailed in connection with the present application, it is respectfully submitted that the claims are allowable for the additional reasons that the invention defined by the language of the claims is neither anticipated by, nor would have been obvious when taken as a whole in view of, the art of record.

Respectfully submitted,

MARSHALL, GERSTEIN & BORUN LLP
6300 Sears Tower
233 South Wacker Drive
Chicago, Illinois 60606-6357
(312) 474-9577

February 19, 2004

By:


Michael R. Hull
Reg. No. 35,902



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PATENT
30205/38008

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Hyung Hwan Kim and
Sang Ick Lee

Serial No.: 10/053,565


Filed: January 22, 2002

For: Nitride CMP Slurry Having
Selectivity to Nitride

Group Art Unit: 3723

Examiner: George Binh Minh Nguyen

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1450, Alexandria, Virginia 22313-1450



Michael R. Hull
Reg. No. 35,902
Attorney for Applicants

COMMENT ON STATEMENT OF REASONS FOR ALLOWANCE

Commissioner for Patents
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Alexandria, Virginia 22313-1450

Sir:

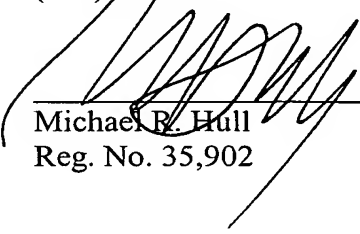
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